

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| | |
|--|---|
| In Re Application of: |) |
| |) |
| Nozawa et al. |) |
| |) |
| Serial No.: 10/771,997 |) |
| |) |
| Filed: February 4, 2004 |) |
| |) |
| For: Manufacturing Method And Apparatus of |) |
| Phase Mask Shift Blank |) |
| |) |
| Examiner: Rodney Glenn McDonald |) |
| |) |
| Confirmation No.: 4072 |) |
| |) |
| Art Unit: 1753 |) |

AMENDMENT F

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicants have the following response to the Office Action of October 17, 2006, a one month extension of time being submitted herewith.

Please amend the above-identified application as follows: